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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09/388,826
Confirmation No. 4483
Filing Date September 1, 1999
Inventor Weimin Li et al.
Assignee Micron Technology, Inc.
Group Art Unit 2813
Examiner E.J. Kielin
Attorney's Docket No. MI22-1208
Customer No. 021567
Title: Low k Interlevel Dielectric Layer Fabrication Methods

RESPONSE TO JUNE 10, 2004 OFFICE ACTION

To: MS Amendment
Commissioner for Patents
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Amendments

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